L1₀-MnAl thin film with high perpendicular magnetic anisotropy grown on L1₀-PtMn seed layer

°L. J. Yu¹, M. Oogane¹, M. Tsunoda², Y. Ando¹

Department of Applied Physics, Tohoku Univ.¹, Department of Electrical Engineering, Tohoku Univ.²

Spin-orbit torque (SOT) induced magnetization switching in high spin Hall angle (SHA) material / ferromagnet (FM) heterostructures has been devoted lots of research attention as it shows promise for future ultrafast and power conservation magnetic memories [1]. For FM layers, magnetic thin films with high perpendicular magnetic anisotropy (PMA) are needed for a prolonged data retention, which promote research of Mn-based alloys, such as L1₀-MnAl with high PMA [2]. Comparing to those heavy metals with high SHA such as Pt, W, Ta, etc., Mn-based L1₀ and L1₂ type antiferromagets (AFM) XMn_Y (X=Ir, Pt, etc., Y=1, 3) are of significant interest not only due to their simple structure as well as the possibility of depositing Mn-based alloys with high PMA epitaxially on them [3], but also their possess high SHA [4-6]. Although both L1₀-MnAl and L1₀-PtMn show application prospects for memory devices, experimental reports about epitaxial growth of MnAl on PtMn are absent. In this work, we report the crystal and magnetic properties of L1₀-MnAl thin films deposited on L1₀-PtMn seed layer.

All the samples were prepared by magnetron sputtering system. The stacking structure was MgO(001) sub. / PtMn (15) / MnAl (3-40) / Ta (3) in nm. We tuned substrate temperature (T_s), post annealing temperature (T_a), and post annealing time to improve the L1₀ crystal orientation of both MnAl and PtMn.

Fig. 1 shows the thickness dependence of magnetic properties of prepared MnAl films. Although PMA magnitude K_u decreased rapidly with decreasing MnAl thickness, we have still measured a relative high K_u around 3 Merg/cc in the 3nm MnAl film. The decreased K_u with decreasing thickness is regarded as insufficient L1₀ structure of MnAl in thin film region since saturation magnetization M_s also decreased. This work was supported in part by GP-spin program



Fig. 2 Magnetic properties dependence of different MnAl thickness.

- 1. R. Ramaswamy, J. M. Lee, K. Cai, H. Yang, Appl. Phys. Rev. 5, 031107 (2018).
- 2. S. Mizukami et al., Scr. Mater. 118, 70-74 (2016).
- 3. J. Jeong et al., Nat. Commun. 7, 10276 (2016).
- 4. W. Zhang et al., Phys. Rev. Lett. 113, 196602 (2014).
- 5. W. Zhang et al., Phys. Rev. B 92, 144405 (2015).
- 6. Y. Ou, S. Shi, D. Ralph, R. Buhrman, Phys. Rev. B 93, 220405 (2016).